

	Type	L #	Hits	Search Text	DBs	Time Stamp
1	BRS	L1	2763	(x ADJ (ray OR radiation)) WITH (EUV OR (extreme ADJ ultraviolet))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWE NT; IBM_TDB	2006/06/17 14:02
2	BRS	L2	655679	focus\$4	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWE NT; IBM_TDB	2006/06/17 14:02
3	BRS	L3	1455	1 AND 2	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWE NT; IBM_TDB	2006/06/17 14:02
4	BRS	L4	2437237	substrate OR wafer	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWE NT; IBM_TDB	2006/06/17 14:03

	Type	L #	Hits	Search Text	DBs	Time Stamp
5	BRS	L5	1346	3 AND 4	US- PGPUB; USPAT; USOCR; EPO; JPO; DERWE NT; IBM_TD B	2006/06/17 14:03
6	BRS	L6	574895	mask OR reticle	US- PGPUB; USPAT; USOCR; EPO; JPO; DERWE NT; IBM_TD B	2006/06/17 14:08
7	BRS	L7	1249	5 AND 6	US- PGPUB; USPAT; USOCR; EPO; JPO; DERWE NT; IBM_TD B	2006/06/17 14:05
8	BRS	L8	31742	"378"/\$.ccls.	US- PGPUB; USPAT; USOCR; EPO; JPO; DERWE NT; IBM_TD B	2006/06/17 14:20

	Type	L #	Hits	Search Text	DBs	Time Stamp
9	BRS	L9	164	7 AND 8	US- PGPUB; USPAT; USOCR; EPO; JPO; DERWE NT; IBM_TD B	2006/06/17 14:20